## **Accepted Manuscript**

Thickness-controlled multilayer hexagonal boron nitride film prepared by plasmaenhanced chemical vapor deposition

Ji-Hoon Park, Soo Ho Choi, Jiong Zhao, Seunghyun Song, Woochul Yang, Soo Min Kim, Ki Kang Kim, Young Hee Lee

PII: \$1567-1739(16)30099-2

DOI: 10.1016/j.cap.2016.03.025

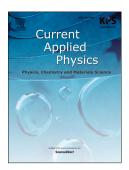
Reference: CAP 4218

To appear in: Current Applied Physics

Received Date: 18 January 2016
Revised Date: 19 March 2016
Accepted Date: 21 March 2016

Please cite this article as: J.-H. Park, S.H. Choi, J. Zhao, S. Song, W. Yang, S.M. Kim, K.K. Kim, Y.H. Lee, Thickness-controlled multilayer hexagonal boron nitride film prepared by plasma-enhanced chemical vapor deposition, *Current Applied Physics* (2016), doi: 10.1016/j.cap.2016.03.025.

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## ACCEPTED MANUSCRIPT

Thickness-controlled multilayer hexagonal boron nitride

film prepared by plasma-enhanced chemical vapor

deposition

Ji-Hoon Park<sup>1</sup>, Soo Ho Choi<sup>2</sup>, Jiong Zhao<sup>1</sup>, Seunghyun Song<sup>1</sup>, Woochul Yang<sup>2</sup>, Soo Min Kim<sup>3</sup>, Ki Kang Kim<sup>4,\*</sup>, and Young Hee Lee<sup>1,5,6,\*</sup>

<sup>1</sup>IBS Center for Integrated Nanostructure Physics, Institute for Basic Science (IBS), Sungkyunkwan University, Suwon, 440-746, Republic of Korea. <sup>2</sup>Department of Physics, Dongguk University–Seoul, Seoul, 100-715, Republic of Korea. <sup>3</sup>Institute of Advanced Composite Materials, Korea Institute of Science and Technology (KIST), San 101 Eunha-Ri, Bongdong-Eup, Wanju-Gun, Jeollabuk-Do, 565-902, Republic of Korea. <sup>4</sup>Department of Energy and Materials Engineering, Dongguk University–Seoul, Seoul, 100-715, Republic of Korea. <sup>5</sup>Department of Energy Science, <sup>6</sup>Department of Physics, Sungkyunkwan University, Suwon, 440-746, Republic of Korea.

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\*Corresponding author E-mail: kkkim@dongguk.edu and leeyoung@skku.edu

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